

Title (en)

METHOD AND DEVICE FOR INFLUENCING THE INJECTION PRESSURE DISTRIBUTION ON INJECTORS

Title (de)

VERFAHREN UND VORRICHTUNG ZUR FORMUNG DES EINSPRITZDRUCKVERLAUFS AN INJEKTOREN

Title (fr)

PROCEDE ET DISPOSITIF DESTINES A INFLUENCER LA REPARTITION DE LA PRESSION D'INJECTION SUR DES INJECTEURS

Publication

**EP 1368563 A2 20031210 (DE)**

Application

**EP 01919222 A 20010320**

Priority

- DE 0101059 W 20010320
- DE 10014451 A 20000323

Abstract (en)

[origin: WO0171177A2] The invention relates to a method for influencing the injection pressure distribution (27) on injectors that are, for example, used in injection devices of injection systems of motor vehicles. The injection device comprises a pump section (1) and an injection nozzle section (2). The pump section (1) and the nozzle section (2) communicate via a high-pressure line (3). Control valves (8, 10) are disposed in the pump section (1) and are actuated by an actuator (9). The injection parameters are determined during the pre-injection phase (28), the pressure build-up phase (29) and during the main injection phase (30) by means of the actuation of the actuator (9).

IPC 1-7

**F02M 59/36**

IPC 8 full level

**F02M 45/02** (2006.01); **F02M 45/06** (2006.01); **F02M 51/00** (2006.01); **F02M 59/36** (2006.01); **F02M 59/46** (2006.01)

CPC (source: EP US)

**F02M 45/02** (2013.01 - EP US); **F02M 45/06** (2013.01 - EP US); **F02M 59/366** (2013.01 - EP US)

Citation (search report)

See references of WO 0171177A2

Designated contracting state (EPC)

AT BE CH CY DE DK ES FI FR GB GR IE IT LI LU MC NL PT SE TR

DOCDB simple family (publication)

**WO 0171177 A2 20010927; WO 0171177 A3 20031009;** BR 0105315 A 20020219; CN 1527904 A 20040908; CZ 20014193 A3 20030416;  
DE 10014451 A1 20010927; EP 1368563 A2 20031210; JP 2003528252 A 20030924; US 2002162528 A1 20021107; US 6688278 B2 20040210

DOCDB simple family (application)

**DE 0101059 W 20010320;** BR 0105315 A 20010320; CN 01800644 A 20010320; CZ 20014193 A 20010320; DE 10014451 A 20000323;  
EP 01919222 A 20010320; JP 2001569136 A 20010320; US 97950002 A 20020327